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(54) Title: LOW DIELECTRIC CONSTANT SILICEOUS FILM MANUFACTURING COMPOSITION AND METHODS FOR
PRODUCING CURED FILM AND ELECTRONIC DEVICE USING THE SAME

(57) Abstract: To provide a low dielectric constant siliceous film manufacturing composition capable of forming a low dielectric
constant siliceous film with dispersed pores having excellent mechanical properties and stable electrical properties. [Means] The present
invention provides a low dielectric constant siliceous film manufacturing composition comprising: a polysiloxane, a pore-generating
material, a condensation catalyst generator, and a solvent.



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